IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.: 09/919,868

Applicant: Yen-Ting Lu

Filed

August 2, 2001

TC/A.U.

1756

Title

: METHOD FOR REDUCING LINE EDGE

ROUGHNESS OF PATTERNED PHOTORESIST

Examiner

YOUNG, CHRISTOPHER G

Docket No. :

4425-168

Honorable Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

:

## **AMENDMENT**

Sir:

In response to the Official Action mailed on October 21, 2003, please reconsider the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Arguments begin on page 8 of this paper.